Ubs Mulas

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT APPLICATION of

**MORIFUJI** 

Appln. No. 09/493,063

Filed: January 28, 2000

Title: SEMICONDUCTOR DEVICE AND METHOD

OF MANUFACTURING THE SAME

June 7, 2000

## <u>PRELIMINARY AMENDMENT</u>

Hon. Commissioner of Patents and Trademarks Washington, DC 20231

Sir:

Before initial examination, please preliminarily amend the above-identified application as follows:

## **IN THE ABSTRACT**:

Lines 3 and 4, delete "decreases the substrate resistance" and insert -suppresses the influence of the substrate resistance--.

## IN THE SPECIFICATION:

Page 2, line 31, delete "heat" and insert --thermal--.

Page 3, line 21, delete "the substrate resistance is decreased" and insert/--the

influence of the substrate resistance is suppressed-hand

line 22, delete "heat" and insert --thermal--.

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